**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Application of:

Robert S. Chau et al.

Serial No.: 09/654,315

Filed: September 1, 2000

For: DEVICE STRUCTURE AND METHOD FOR REDUCING  
SILICIDE ENCROACHMENT

Mail Stop ISSUE FEE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Examiner: Tran, Thien F.

Art Unit: 2811

**SUBMISSION OF FORMAL DRAWINGS**

Dear Sir:

Enclosed herewith for submission in the United States patent application referenced above are twelve (12) sheets of formal drawings.

If there are any further charges please charge them to Deposit Account No. **02-2666**.

Respectfully submitted,  
BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN

Date: 2/27, 2004

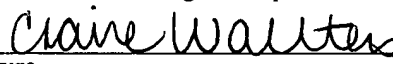
  
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